



PATENT
81790.0211

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Koichi GEN-EI et al.

Serial No: 09/954,475 ✓

Filed: September 14, 2001

For: SEMICONDUCTOR LASER WHICH
REMOVES INFLUENCES FROM
RETURNING LIGHT OF THREE
BEAMS AND METHOD OF
MANUFACTURING THE SAME

Date of NOA: May 20, 2004

Art Unit: 2828

TRANSMITTAL OF FORMAL DRAWINGS

Attn: OFFICIAL DRAFTSPERSON
Mail Stop ISSUE FEE
Commissioner for Patents
P.O. Box 1450
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August 19, 2004

Date of Deposit

Firoozeh Vakilzadeh

Name

Signature

Date

Dear Sir:

In response to the Notice of Allowance dated May 20, 2004, enclosed are the formal drawings (5 sheet(s) – Figure(s) 1-12B) in the above-captioned case. All the drawing changes have been made as requested in the Notice of Allowability.

The Commissioner is hereby authorized to charge any deficiency in payment or credit any overpayment to Deposit Account No. 50-1314. A copy of this Transmittal is enclosed.

Respectfully submitted,

HOGAN & HARTSON L.L.P.

Date: August 19, 2004

By:

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